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Insplorion: Main patent will be approved May 23rd in USA

Insplorion's main patent "Sensor Using Localized Surface Plasmon Resonance (LSPR)" has got now got "issue of notification" and will be approved May 23rd 2017 according to USPTO.

The patent was applied in internationally in May 2010 and has previously been approved in Japan in early 2015, followed by China at the end of 2016. The patent, with application number 13/261,045 now gets the patent number US 9,658,157 covers the possibility to coat the sensor surface with different materials. This is predicted to provide a good protection as it is this methodology that gives the technology its robustness and its specific sensitivity to different molecules. The patent thus covers the technology's main strengths within both business areas, Instruments and Sensor Systems. The patent provides protection in USA until 12 October 2030.

"The fact that our main patent that protect our core technology now also is approved for the American market is of course very positive. With this secured can we boost our sales efforts within the Instrument business as a "Sole Source" is helpful in the procurement process and it will also be a strength in our dialogues with potential partners for the Sensor Systems applications", says Patrik Dahlqvist, CEO of Insplorion.

Questions are answered by:

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